# Revealing the Enhancement of Li Plating/Stripping Efficiency in the TEGDME-based Low-concentration Electrolytes for Anode-free Lithium Metal Batteries

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## Supporting Information

#### Materials

Copper foil ( $\varphi$ 16 mm,  $\tau = 0.2$  mm,  $\geq$ 99.96%) was purchased from Takeuchi Metal Foil & Powder Co., Ltd., and was rinsed with concentrated acetic (denoted as c-HAc, Wako Pure Chemical Industries) for 10 min and thoroughly dried by Ar flow prior to all measurements.<sup>1</sup> The pre-treated Cu foil was assembled with Li ribbon (Sigma Aldrich, 99%) in order to construct the Li||Cu cell. Lithium-battery-grade LiTFSI (99.9%) and TEGDME (>98%) were purchased from Kishida Chemical Co., Ltd. LiTFSI was completely dissolved in TEGDME to make homogeneous solutions with different concentrations in an Ar-filled glovebox (H<sub>2</sub>O < 0.5 ppm, O<sub>2</sub> < 0.2 ppm). As an additive, LiNO<sub>3</sub> (>99.95%, Kanto Chemical Co., Inc.) was added into the LiTFSI-TEGDME solutions to reach a concentration of 0.1 M. The water content in these electrolytes was all less than 30 ppm by Karl-Fischer titration (model: CA-21, Mitsubishi Chemical Analytech Co., Ltd.).

#### **Experimental Methods**

The cycling voltammetry (CV) measurements were conducted using the HZ-7000 system (Hokuto Denko Corporation) in the glovebox. A PTFE-made three-electrode cell was used, with the Cu foil as working electrode and Li ribbon as counter and reference electrode. The measurement conditions include a fixed scanning rate of 10 mV/s, a lower potential limit of -0.5 V or 0.2 V, and an upper potential limit of 3.2 V or 2.2 V vs. Li/Li<sup>+</sup>. The Coulombic efficiency of Li plating/stripping was calculated by Equation (1):

$$CE = \frac{Q \ (stripping)}{Q \ (plating)} \times 100\% \tag{1}$$

where Q(stripping) and Q(plating) represent the charges consumed during Li stripping and in Li plating, respectively, obtained by integrating the corresponding peak areas in current density vs. time curves. The QCM (quartz crystal microbalance) measurement was carried out using the QCA-922 system (Seiko EG&G Co., Ltd.) during the CV scanning. The mass change on the working electrode surface was converted from the recorded frequency change using the Sauerbrey equation (Equation (2)):<sup>2</sup>

$$\Delta f = -\frac{2f_0^2}{A\sqrt{\rho_q \mu_q}} \Delta m \tag{2}$$

where  $f_0$  and  $\Delta f$  are the fundamental resonant frequency and the change in frequency (Hz) respectively,  $\Delta m$  is the mass change (µg), A is the active electrode area deposited on the crystal (cm<sup>2</sup>),  $\rho_q$  is the density of quartz (2.648 g/cm<sup>3</sup>), and  $\mu_q$  is the shear modulus of quartz (2.947 × 10<sup>11</sup> g/cm·s<sup>2</sup>). The  $f_0$  and A values for the Cu quartz electrode used in this study are 9.04 MHz and 0.196 cm<sup>2</sup>, respectively. Therefore,  $\Delta m$  on the crystal surface can be determined for a given  $\Delta f$  during a QCM experiment. In the present study, a customized three-electrode electrochemical cell made of a PTFE bottom and a glass chamber was used. An AT-cut quartz crystal deposited by Cu thin film was used as working electrode, and Li ribbon was used as counter and reference electrode. The Cu quartz electrode was rinsed with c-HAc for 10 min and thoroughly dried by argon flow prior to the experiment. The QCM cell was kept for 30 min before each measurement to stabilize the open circuit potential (OCP),  $\Delta m$ , and  $\Delta R$ . During the CV scanning, the values of  $\Delta m$  and  $\Delta R$  were simultaneously recorded.

However, it should be noted that, the deviation could occur when applying above Sauerbrey equation to study an electrolyte/electrode interface, in which the influence of density and viscosity of electrolyte due to the contact with electrode surface should be considered.<sup>3,4</sup> Under such circumstances, the measured  $\Delta f$  is expressed by Equation (3):

$$\Delta f = \Delta f_m + \Delta f_{\eta\rho} \tag{3}$$

Where  $\Delta f_{\rm m}$  is due to the actual deposited product, and  $\Delta f_{\eta\rho}$  is due to electrolyte contact which is obtained from Equation (4):<sup>3</sup>

$$\Delta f_{\eta\rho} = -f_{0}^{3/2} \sqrt{\frac{\rho_L \eta_L}{\pi \rho_q \mu_q}} \tag{4}$$

where  $\rho_L$  and  $\eta_L$  are the density and viscosity of the electrolyte, which are subject to change during measurement. In the meantime,  $\Delta R$  is also dependent on  $\rho_L$  and  $\eta_L$  (Equation (5)):

$$\Delta R = \frac{A_{\sqrt{2\pi f_0 \rho_L \eta_L}}}{k^2} \tag{5}$$

where k is called electromechanical coupling factor, which is a specific value for each electrolyte.<sup>4</sup> By combining Equation (4) and (5), one can get the following equation (Equation (6)):

$$\Delta f_{\eta\rho} = -\frac{f_0 \Delta R k^2}{A \pi \sqrt{2\rho_q \mu_q}} \tag{6}$$

in which the initial R and  $f_{\eta\rho}$  values can be confirmed as soon as the electrode is immersed in the electrolyte, while the latter is the difference between the resonant frequencies before and after immersing electrolyte, respectively. Then k can be determined according to Equation (6), and thereafter, the real-time  $\Delta f_{\eta\rho}$  during measurement can be obtained with the recorded  $\Delta R$ . In this study, the measured  $\Delta f$  was converted into  $\Delta f_{\rm m}$  for calculating the real mass change.

The X-ray photoelectron spectroscopy (XPS) depth profile was investigated with the VersaProbe II X-ray Photoelectron Spectrometer (ULVAC-PHI, Inc.) under ultra-high-vacuum condition using monochromatic Al K $\alpha$  (1486.6 eV) as the X-ray source. The samples were prepared by disassembling Li||Cu cells after 50 Li plating/stripping cycles

in each electrolyte, and were loaded in a portable transfer vessel without exposure to air before moving to the XPS spectrometer. The surface of sample was sputtered by  $Ar^+$  bombardment with a parameter of 2 keV & 20 mA. The F 1s peak at 685.2 eV was used as a reference.

The *in situ* SERS (surface-enhanced Raman spectroscopy) spectra was recorded with a confocal microscope spectrometer (RamanTouch-VIS-NIR) in a super-dry room (water contents < 0.1 ppm, Shinryo Corp.). A homemade three-electrode cell was used, and the roughened Cu foil was prepared by "cathodic deposition" method,<sup>5</sup> and was used as the working electrode, The counter electrode and the reference electrode were Li metal. The 785 nm laser was focused on the Cu surface through a 10× long working distance lens with an exposure time of 10 s. The grating was 300 grooves mm<sup>-1</sup>. During the first cycle, the spectra were recorded during the negative scanning from OCP to -0.5 V and then positive scanning to 2.2 V at 10 mV/s, followed by a positive scanning from 2.2 V to 3.2 V at 1 mV/s so as to carefully check the OSS process. From the second cycle, the spectra were recorded during the CV scanning between 3.2 V and -0.5 V at 10 mV/s. The working electrode potential was kept constant for 3 min before each SERS measurement.

Scanning electron microscope (SEM) measurement was conducted in the super-dry room using VE-8800 (Keyence) for the observation of the surface morphologies of SEI layers.



Figure S1. 50-cycle CV curves measured in 0.4LT, 0.4LT w/o OSS, 0.4LTLN, 2.0LT and 2.0LTLN. Potential range:  $-0.5 \sim 3.2$  V vs. Li/Li<sup>+</sup>. Scan rate: 10 mV/s.



**Figure S2.** Cycling-dependent variation of peak REL, RSS' and OSS measured in 0.4LT, 0.4LT w/o OSS, 0.4LTLN, 2.0LT and 2.0LTLN. Scan rate: 10 mV/s. Peak REL and RSS' at selected cycles were marked by cross and asterisk symbols, respectively, for a better understanding of peak variation.



**Figure S3.** SEM morphologies and corresponding optical images of electrode surface in 0.4LT with and w/o OSS, and 0.4LTLN with and w/o OSS after 50 cycles.



**Figure S4.** *In situ* SERS spectra recorded before (2.2 V) and after (3.0 V) reaction OSS during the first cycle in 0.4LT, 0.4LTLN, 2.0LT and 2.0LTLN.



Figure S5. The calculated MPE values from the  $\Delta$ m-charge curves (solid bold line), and the potential-charge curves (dotted line) during the reaction OSS measured in (a) 0.4LT and (b) 0.4LTLN. Totally 3 samples (represented by 3 colors) were tested for each electrolyte. The positive and negative MPE indicate the increase and decrease of mass, respectively.

Initial MPE	Subsequent MPE	Ratio of Li <sub>2</sub> O oxidation
		charges*
6	-5	85%
-24	-10	83%
-50	-12	87%

Table S1. The ratio of Li<sub>2</sub>O oxidation charges over total charges

### \* The calculation process:

- 1. The ratio of the charge consumed by Li<sub>2</sub>O oxidation over the total charges can be set as X.
- Since the MPE of Li<sub>2</sub>O oxidation to Li<sub>2</sub>O<sub>2</sub> is -7, assuming that the change of MPE was mostly due to Li<sub>2</sub>O oxidation, we can obtain the following equation: A(1-X)-7X=B, where A and B represent the initial MPE and the subsequent MPE, respectively.
- 3. The above equation can be changed to: X=(A-B)/(A+7), then X can be obtained.



**Figure S6**. Enlarged view of the second-cycle CV curves measured in the 0.1 M LiNO<sub>3</sub>-TEGDME electrolyte under 3 different potential ranges. The redox a/(a', a'', a''') indicates the LiNO<sub>3</sub>-related reactions, where the oxidative reaction *a* occurs within the OSS region; The redox b/(b', b'') indicates the SEI-related reactions.



**Figure S7.** Potential-dependent SERS intensity of v(C=C) band in 0.4LT, 0.4LT w/o OSS, 0.4LTLN, 2.0LT and 2.0LTLN. The SERS spectra were recorded at -0.5 V during cycle 1, 2, 3, 5 and 10.

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